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U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE

INFORMATION DISCLOSURE STATEMENT
BY APPLICANT

(USE SEVERAL SHEETS IF NECESSARY)

FILING DATE
February 19, 2004

APPLICATION NO.
10/782,997

APPLICANT
Smythe et al.

FILING DATE
February 19, 2004

GROUP
Unknown

U.S. PATENT DOCUMENTS						
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPROPRIATE)
CN	5,087,586	2/11/92	Chan et al.			
CIN	5,447,884	9/5/95	Fahey et al.			
CN	5,492,858	2/20/096	Bose et al.			
CN	5,702,976	12/30/97	Schuegraf et al.			
CN	6,027,982	2/22/00	Peidous et al.			
CN	6,037,238	3/14/00	Chang et al.			
CN	6,518,148 B1	2/11/03	Cheng et al.			
CN_	6,657,276 B1	12/2/03	Karlsson et al.			

FOREIGN PATENT DOCUMENTS							
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
			·				
		1					

EXAMINER INITIAL	OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)				
CN	Peters, Laura, "Choices and Challenges for Shallow Trench Isolation," <u>Semiconductor International</u> , Website www.ree-electronics.com, 6 pages, April 1, 1999.				
	Advertisement entitled "Pelyeilazane SODe Spinfil™ 100 Serice for STI/PMD Application."				

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EXAMINER	/Christy Novacek/	DATE CONSIDERED	07/25/2006			
*EXAMINER: INITIAL IF CITATION CONSIDERED, WHETHER OR NOT CITATION IS IN CONFORMANCE WITH MPEP 609: DRAW LINE THROUGH CITATION IF NOT						

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